

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



Re Patent Application:
Anguel Nikolov

Serial No.: 10/633,372

Filing Date: August 1, 2003

For: Precision Phase Retardation Devices
And Method of Making Same

Group Art Unit: 2872

Attorney Docket No.: 02-40171-US

Examiner: Curtis, Craig

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Applicant submits herewith copies of references or other information of which it is aware that it believes may be material to the examination of this application, and in respect of which, there may be a duty to disclose under 37 C.F.R. § 1.56 and in accordance with 37 C.F.R. §§ 1.97-1.98.

The filing of this information disclosure statement shall not be construed as a representation that a search has been made (37 C.F.R. 1.97(g)), an admission that the information cited is, or is considered to be, material to patentability, or that no other material information may or may not exist.

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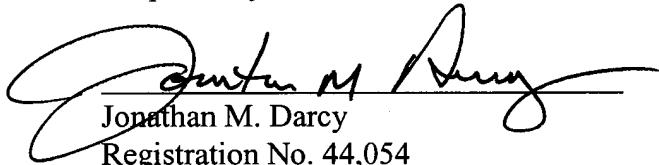
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The Examiner is respectfully requested to review the references identified herewith and make them of record in the instant application as required by M.P.E.P. § 609. The Examiner is also requested to initial one copy of Form 1449 and return same to the undersigned.

Respectfully submitted,



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Enclosures: PTO Form 1449
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ATTY. DOCKET NO. 02-40171-US	10/633,372
APPLICANT Anguel Nikolov et al.	
FILING DATE August 1, 2003	GROUP 2872

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	4,615,034	09/86	Von Gunten et al			
	4,638,669	01/87	Chou			
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	4,732,444	03/88	Papuchon et al			
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